APPLICATION DATA SHEET PROTECTIFIC 12 APR 2006

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Application Information:

Title of Invention:

METHOD FOR FORMING WIRING, METHOD FOR

MANUFACTURING THIN FILM TRANSISTOR OR AND

DROPLET DISCHARGING METHOD

Application Type:

regular, utility

Attorney Docket Number: 740756-2947

Botanic Information:

Publication Information:

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22204

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as our attorney(s) or agent(s) to prosecute the application identified above, and to transact all business in the United States Patent and Trademark Office connected therewith.

Domestic Priority Information:

This is a National Stage of JP application number PCT/JP2004/016181, filed 2004-10-25, now pending.

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